



Seat No. : _____

TA-115

April-2013

M.Sc. Sem. II

409 : PHYSICS

(Solid State Properties and Physics of Semiconductor)

Time : 3 Hours]

[Max. Marks : 70

- Instructions :** (1) Attempt **all** questions.
(2) Symbols used have their usual meanings.

1. (a) What is Curie-Weiss law ? Derive it. Also derive the equations for energy density and heat capacity of the ferromagnetic substance on the basis of the mean field theory. 7

OR

Obtain the dispersion relation of Magnons in Ferromagnets.

- (b) Differentiate between ferromagnet and ferrimagnet substances. Discuss the Neel model of ferrimagnetism. 7

OR

Obtain the necessary expression for the Bloch $T^{3/2}$ law.

2. (a) (i) Explain Meissner effect. How superconductors are classified in to Type I and Type II ? 4
(ii) For Nb : $Z = 5$ and $T_c = 9.26$ K.
For Pb : $Z = 4$ and $T_c = 7.20$ K. Estimate T_c for Hg ($Z = 2$). 3

OR

- (a) By deriving the necessary expression, explain current-voltage characteristics of the DC Josephson effect. 7

- (b) Obtain expressions for London penetration depth and coherence length. 7

OR

- (b) (i) Write the underlying assumptions in BCS theory. 4
(ii) Find the angle θ at which the $B_c(T) - T$ curve meets the T-axis. 3

3. (a) Discuss Hall effect. Using necessary equations, explain how it is used for determination of mobility of a semiconductor? 7

OR

- (a) (i) Explain how and why Fermi level changes with temperature. 4
(ii) A silicon bar 0.1 cm long and $100 \mu\text{m}^2$ in cross sectional area is doped with 10^{17}cm^{-3} phosphorus atoms. Find the current at 300 K with 10 V applied. The electron mobility in silicon is $700 \text{cm}^2 \text{V}^{-1} \text{Sec}^{-1}$. 3

- (b) Define density of states. Use momentum diagram to obtain an expression for density of states in a semiconductors. State its importance. 7

OR

State and prove the law of mass action. Mention at least two applications of it.

4. (a) For a semiconductor $p-n$ junction, derive an expression of depletion layer width when suitable external bias is applied to the junction. 7

OR

Derive an equation of diode rectification and explain the $I-V$ curve from it.

- (b) Draw energy band diagram when two metals are joined. Explain the concept of contact potential. How it can be extended to semiconductor junctions? 7

OR

- (b) Explain the terms :
(i) Abrupt $p-n$ junction. 4
(ii) Contact potential. 3

5. Answer the following in brief : (each carry **one** mark) 14

- (1) The quantized unit of spin wave energy is called a _____.
(a) megneton (b) megnon
(c) spintron (d) photon

- (2) The Curie law is valid for
- (a) diamagnet (b) paramagnet
(c) ferromagnet (d) all substances
- (3) In the long wave length limit, the magnon dispersion relation reduces to
- (a) $\omega = \frac{4J_{ex}S}{\hbar} |ka|$ (b) $\omega = \frac{4J_{ex}S}{\hbar} \cos(ka)$
(c) $\omega = \frac{4J_{ex}S}{\hbar} \sin(ka)$ (d) $\omega = \frac{4J_{ex}S}{\hbar}$
- (4) The isotope effect coefficient is
- (a) zero (b) 1/2
(c) 2 (d) infinite
- (5) In the ac Josephson effect, the current has an oscillatory component of angular frequency $\omega =$ _____
- (a) $2eV/\hbar$ (b) $2eV/(\hbar c)$
(c) $eV/(2\hbar)$ (d) $2\hbar c/(eV)$
- (6) In the macroscopic quantum interference the current is maximum when _____.
- (a) $e\phi/\hbar c = s\pi$ with $s =$ integer
(b) $2e\phi/\hbar c = s\pi$ with $s =$ integer
(c) $\phi\hbar/c = s\pi$ with $s =$ integer
(d) $\hbar c/e\phi = s\pi$ with $s =$ integer
- (7) In the BCS theory
- (a) $T_C = 114\theta_D \exp[-1/UD(E_F)]$
(b) $T_C = 114\theta_D \exp[-UD(E_F)]$
(c) $T_C = 1.14\theta_D \exp[-1/UD(E_F)]$
(d) $T_C = 1.14\theta_D \exp[-UD(E_F)]$
- (8) Plot a graph of excess charge carrier density versus time for recombination process in a p -type semiconductor.
- (9) Why the location of acceptor state is close to top of the valance band ?
- (10) Draw the charge carrier density profile of an abrupt p - n junction.

- (11) State the importance of metal work function.
 - (12) Plot the mobility versus donor density (N_d) of *n*-type silicon.
 - (13) Define Fermi factor. Give its unit.
 - (14) Why “trap” is required for recombination process in semiconductor ?
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